ERRATUM

To the article “Wettability of Thin Silicate-Containing Hydroxyapatite Films Formed by RF-Magnetron Sputtering” by S. N. Gorodzha, M. A. Surmeneva, R. A. Surmenev, M. V. Gribennikov, V. F. Pichugin, A. A. Sharonova, A. A. Pustovalova, O. Prymack, M. Epple, A. Wittmar, M. Ulbricht, K. V. Gogolinskii, and K. S. Kravchuk, Vol. 56, No. 10, pp. 1163–1169, 2014.

There was a misprint in the eighth author’s name. It should read O. Prymak instead of O. Prymack.